Date Mailed: April 22, 2002

Sheet 1 of 1

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	APR 2.2.2002
	FIRADEMANTS

ORMATION DISCLOSURE STATEMENT

Docket Number: 40222.0003USCI

Application Number: 10/023,365

IN AN APPLICATION

(Use several sheets if necessary)

Applicant: Teruo Umemoto

Filing Date: December 14,

Group Art Unit: 174T

A53

				U.S. PATENT DOCUMEN	TS				
EXAMINER INITIAL			DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE		
(m)	5,902,907		05/11/99	Takahashi et al,	568	321			
(W)	5,942,641		08/24/99	Tanaka et al.	560	139			
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		 	F	DREIGN PATENT DOCUM	ENTS				
	DOCUMENT NO.		DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION		
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	SHO 61-271323		12/01/86	Japan			х		
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		отн	ER DOCUMEN	ITS (Including Author, Title,	Date, Pertinent Pag	zes, Etc.)			
	1999 A Precursor Route to 2,7-Poly (9-fluorenone), Macromolecules 32, 4519-4524, Uckert et al.								
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	September 23, 1985	The Polyfluorenes: A Family of Versatile Electroactive Polymers: Electropolymerization of Fluorenes; New Journal of Chemistry, Vol. 10, Rault-Berthelot et al.							
	2000 💥	2,7-Poly (9-fluorenone); A Trap-Free Electron-Injection Material with a High Charge Carrier Mobility for Use in Light- Emitting Diodes, Advances Materials, 2000, 12, No. 12, Uckert et al.							
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PATENT TRADEMARK OFFICE

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DATE CONSIDERED

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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this term for next communication to the Applicant.